

Edition 1.0 2018-11

INTERNATIONAL STANDARD



Semiconductor devices – Flexible and strechable semiconductor devices – Part 3: Evaluation of thin film transistor characteristics on flexible substrates under bulging

INTERNATIONAL ELECTROTECHNICAL COMMISSION

ICS 31.080.99 ISBN 978-2-8322-6161-3

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CONTENTS

FOREWORD	3
INTRODUCTION	5
1 Scope	6
2 Normative references	6
3 Terms and definitions	6
4 Test piece	6
4.1 General	
4.2 Size of a test piece	
4.3 Measurement of dimensions	
4.4 Storage prior to testing	
5 Test apparatus and procedure	
5.1 General	
5.2 Test apparatus	
5.2.1 General	
5.2.2 Apparatus	8
5.3 Test procedure and analysis	12
5.3.1 Test procedure	12
5.3.2 Data analysis	14
6 Test report	17
Annex A (informative) Other types of electrical and mechanical test equipments	18
A.1 Absorption type electrical and mechanical test equipment with heating system	18
A.2 Bulging-type electrical and mechanical test equipment with halogen lamp heating system)
Annex B (informative) Failure pressure estimation	20
Bibliography	22
Figure 1 Proceure chember open window chapes	0
Figure 1 – Pressure chamber open window shapes Figure 2 – Typical example of bulging-type mechanical and electrical measurement	
test apparatus with heating system	11
Figure 3 – Exemplary schematics of pressure chamber, pressure chamber open window	11
Figure 4 – Exemplary schematic of wire bonding	12
Figure 5 – Exemplary DC characteristics for determining (a) μ_{lin} (b) μ_{sat} and (c) SS	16
Figure 6 – Representative bulge test data showing pressure-deflection relation for APd/SiN _x	Ag-
Figure A.1 – Exemplary schematic of absorption-type electrical and mechanical tes equipment with heating system	
Figure A.2 – Exemplary schematic of bulging-type electrical and mechanical test equipment with halogen lamp heating system	19
Figure B.1 – Schematic for failure pressure estimation for 100 µm-thick polyimide assuming yield and tensile strength of 69 MPa and 231 MPa	20
Table B.1 – Flexible substrate information (polyimide)	20
Table B.2 – Pressure calculation results	21

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SEMICONDUCTOR DEVICES – FLEXIBLE AND STRECHABLE SEMICONDUCTOR DEVICES –

Part 3: Evaluation of thin film transistor characteristics on flexible substrates under bulging

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International Standard IEC 62951-3 has been prepared by IEC technical committee 47: Semiconductor devices.

The text of this International Standard is based on the following documents:

FDIS	Report on voting
47/2492/FDIS	47/2511/RVD

Full information on the voting for the approval of this International Standard can be found in the report on voting indicated in the above table.

This document has been drafted in accordance with the ISO/IEC Directives, Part 2.

A list of all parts in the IEC 62951 series, published under the general title *Semiconductor devices* – *Flexible and stretchable semiconductor devices*, can be found on the IEC website.

The committee has decided that the contents of this document will remain unchanged until the stability date indicated on the IEC website under "http://webstore.iec.ch" in the data related to the specific document. At this date, the document will be

- · reconfirmed,
- · withdrawn,
- · replaced by a revised edition, or
- amended.

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INTRODUCTION

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SEMICONDUCTOR DEVICES – FLEXIBLE AND STRECHABLE SEMICONDUCTOR DEVICES –

Part 3: Evaluation of thin film transistor characteristics on flexible substrates under bulging

1 Scope

This part of IEC 62951 specifies the method for evaluating thin film transistor characteristics on flexible substrates under bulging. The thin film transistor is fabricated on flexible substrates, including polyethylene terephthalate (PET), polyimide (PI), elastomer and others. The stress is applied by applying a uniformly-distributed pressure to the flexible substrate using the equipment.

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

IEC 62047-17, Semiconductor devices – Micro-electromechanical devices – Part 17: Bulge test method for measuring mechanical properties of thin films

IEC 60747-8, Semiconductor devices – Discrete devices – Part 8: Field-effect transistors